

# **Nano-structured magnetic materials: novel physics and emerging technologies**

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Hitachi Global Storage Technologies*

Introduction to recording, scaling and nano 'issues'  
Opportunities for nanosciences

Novel materials and architectures  
Advance characterization

**HITACHI**  
**Inspire the Next**

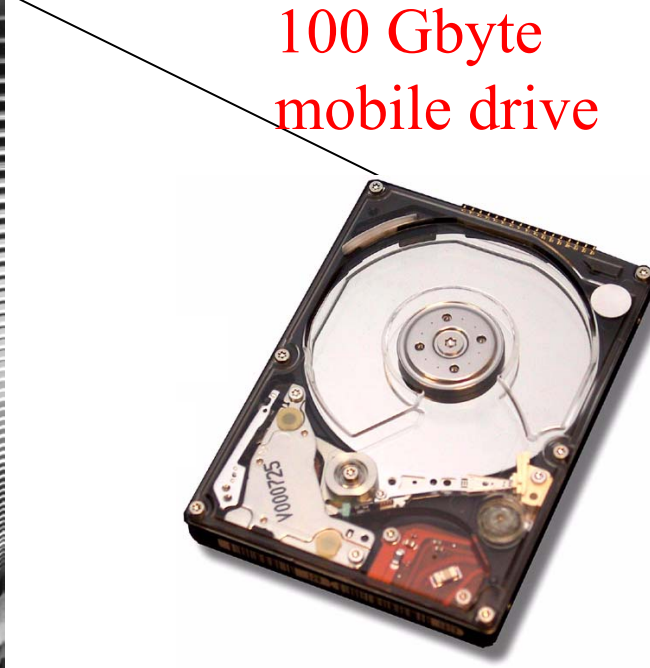


# Product scaling

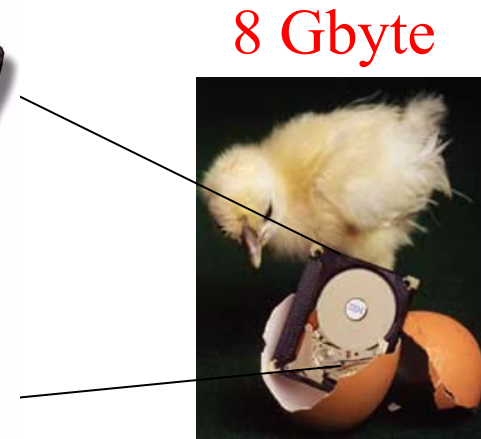
Smaller & faster



2 kbits/in<sup>2</sup>  
70 kbits/s  
50x 24 in dia disks  
\$10,000/Mbyte

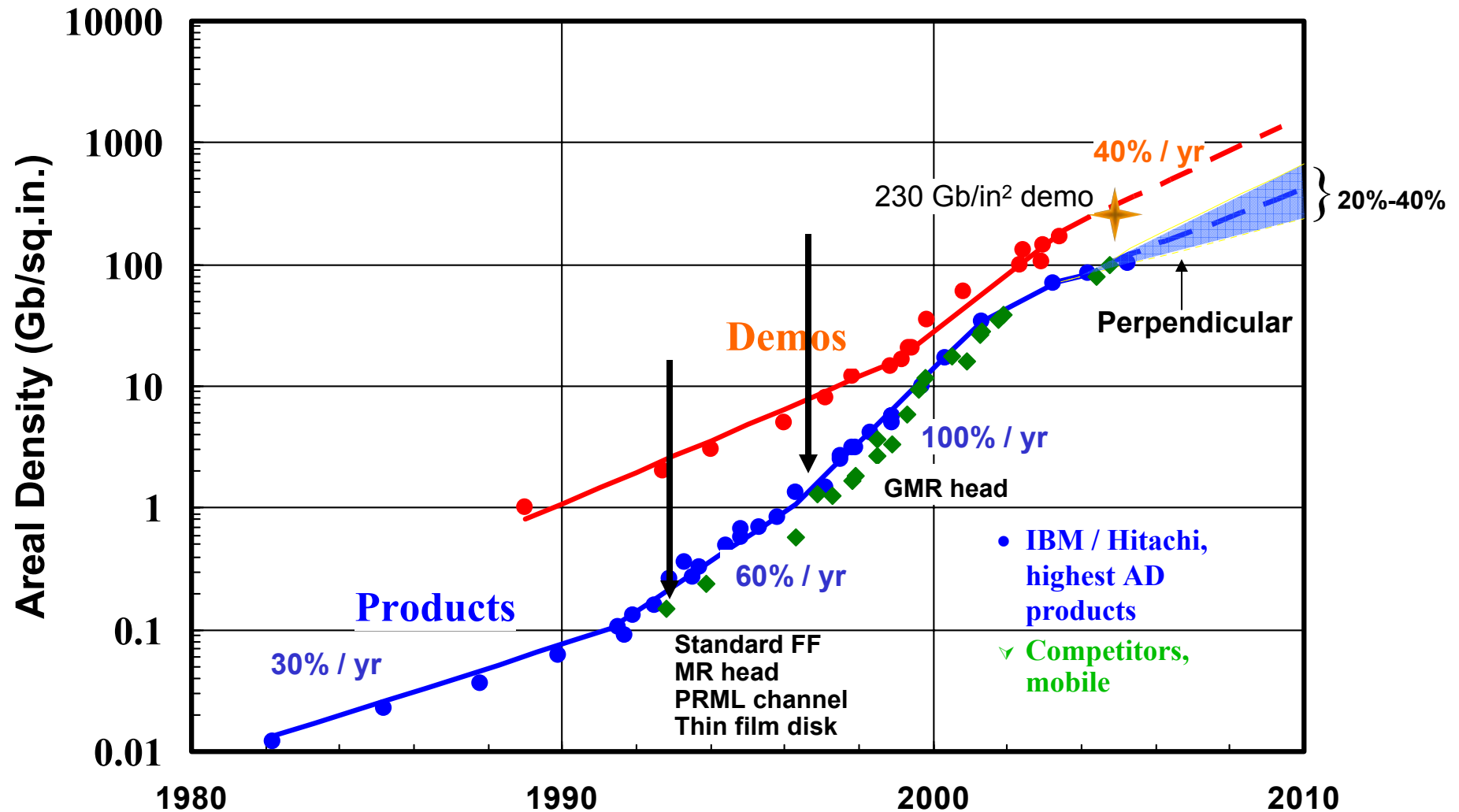


100 Gbits/in<sup>2</sup>  
630 Mb/s  
2 x 2.5" glass disks  
<\$0.01/Mbyte

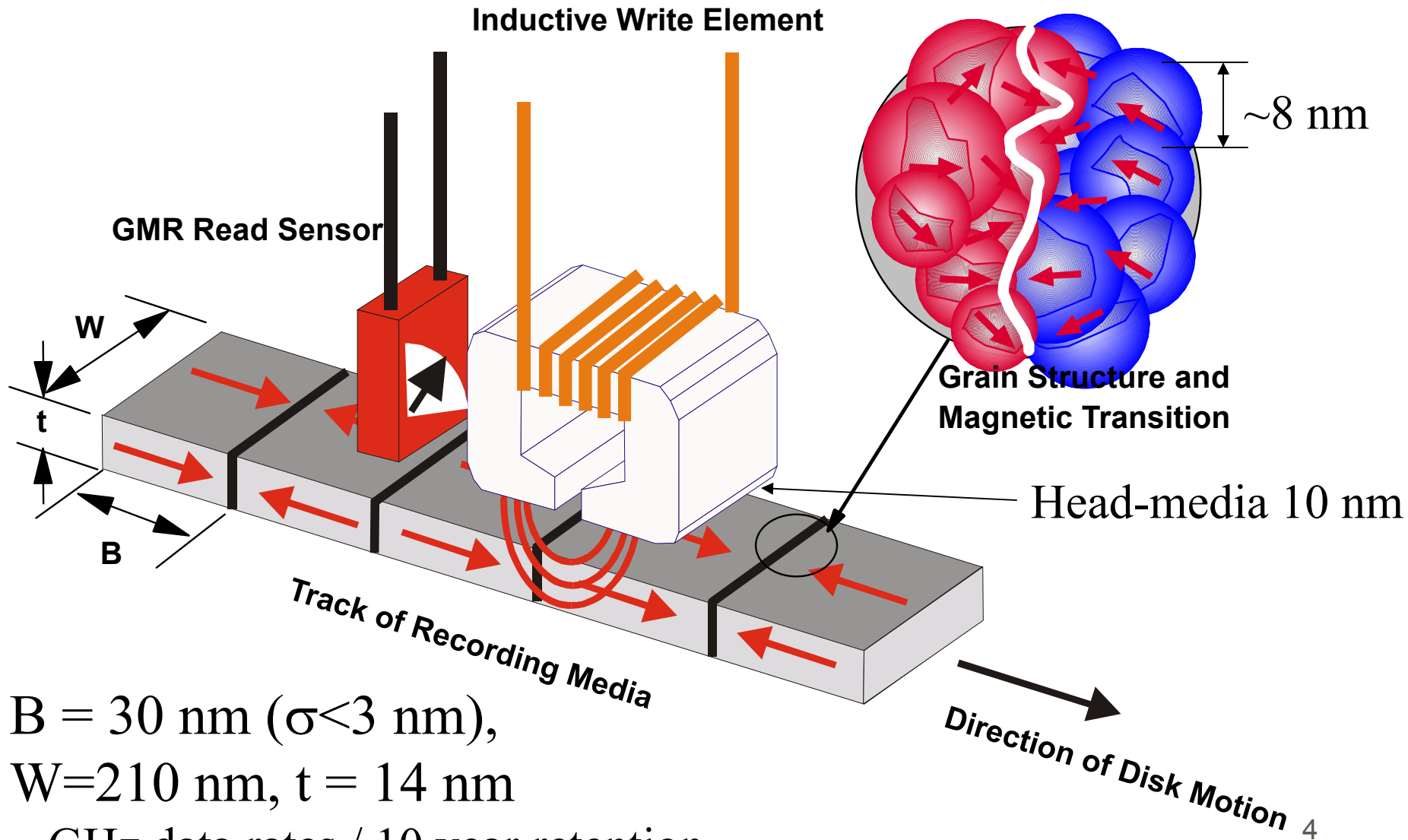


Microdrive  
78 Gbits/in<sup>2</sup>  
1 x 1" dia disk

# Areal density trends

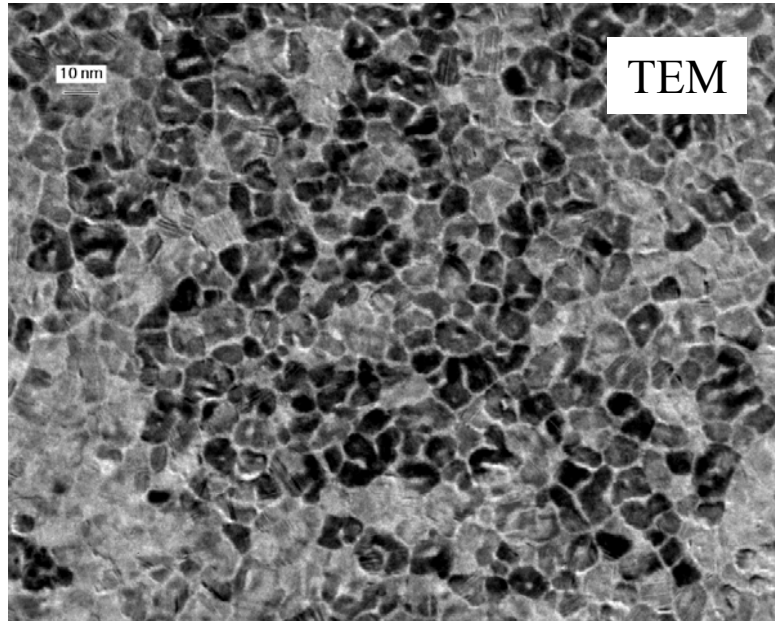


# Magnetic recording components



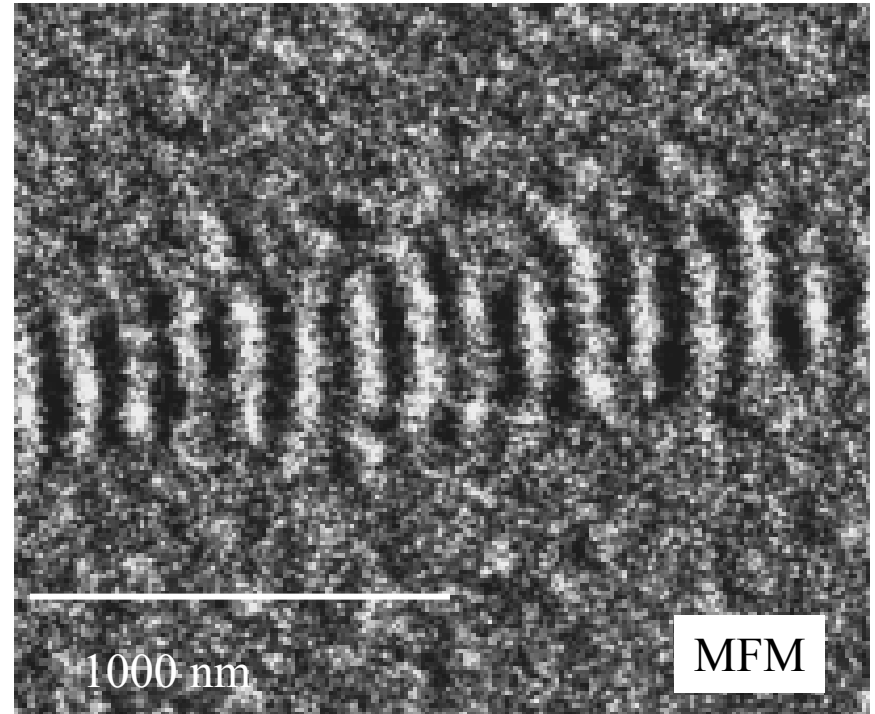
# Media: TEM and MFM images

CoPtCrB alloy



100 nm

$\langle D \rangle = 8.5 \text{ nm}$

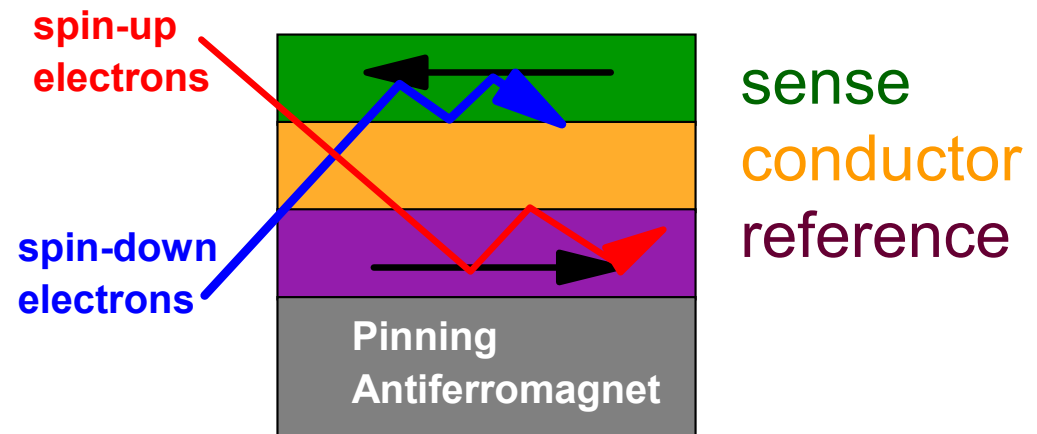
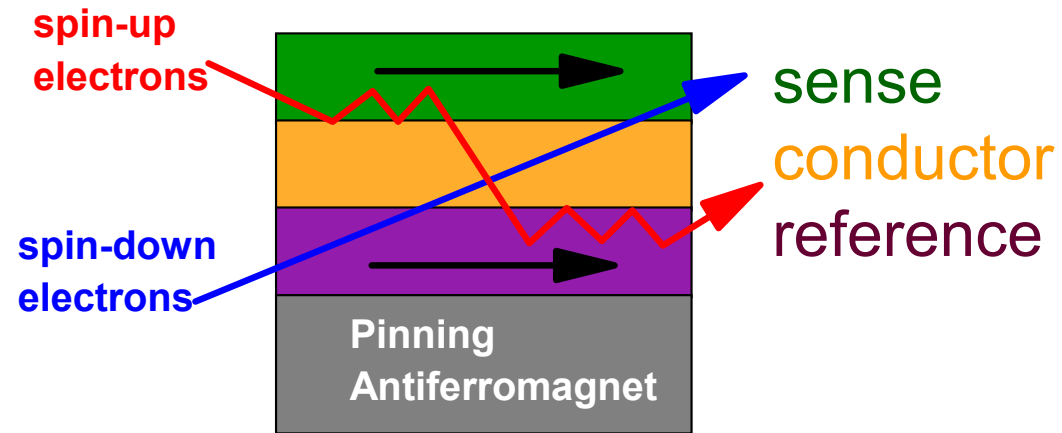
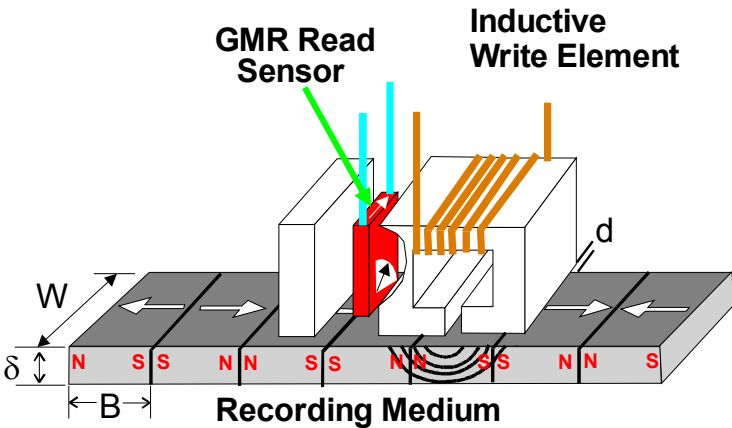


$$\text{SNR} \propto \sqrt{N} \quad \# \text{ grains/bit}$$

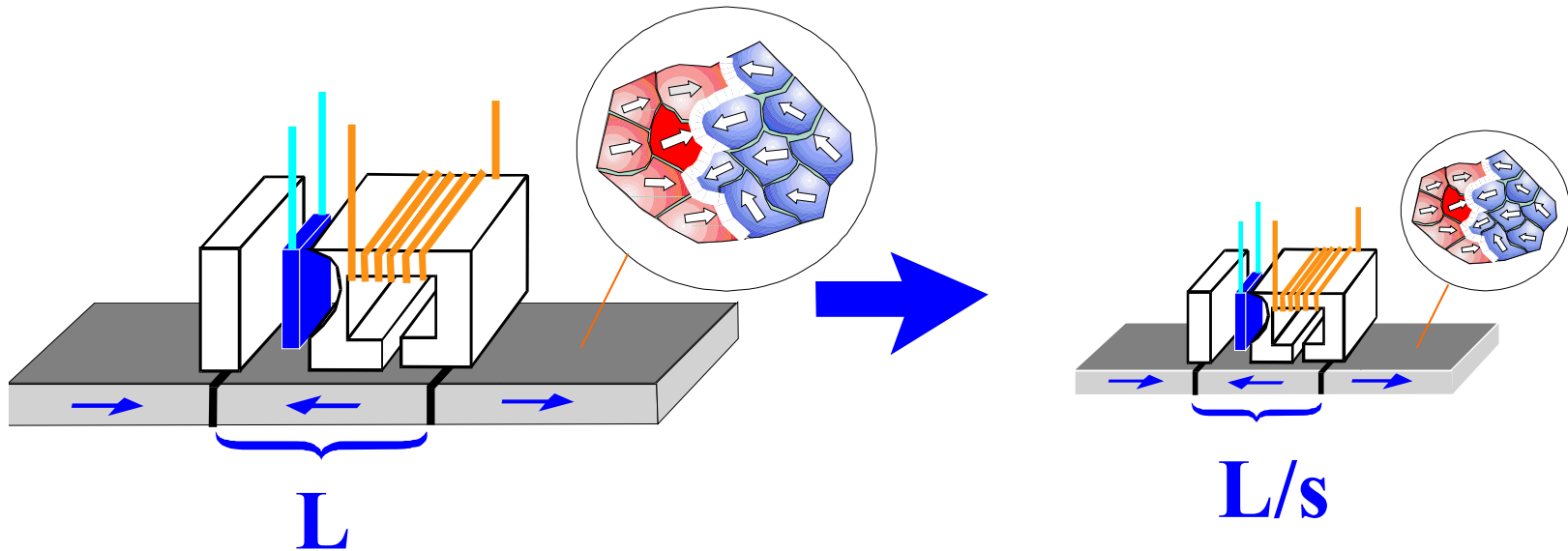
More uniform the grains the better

Eames, et al.  
U. of Minn.

# GMR sensor



# Scaling



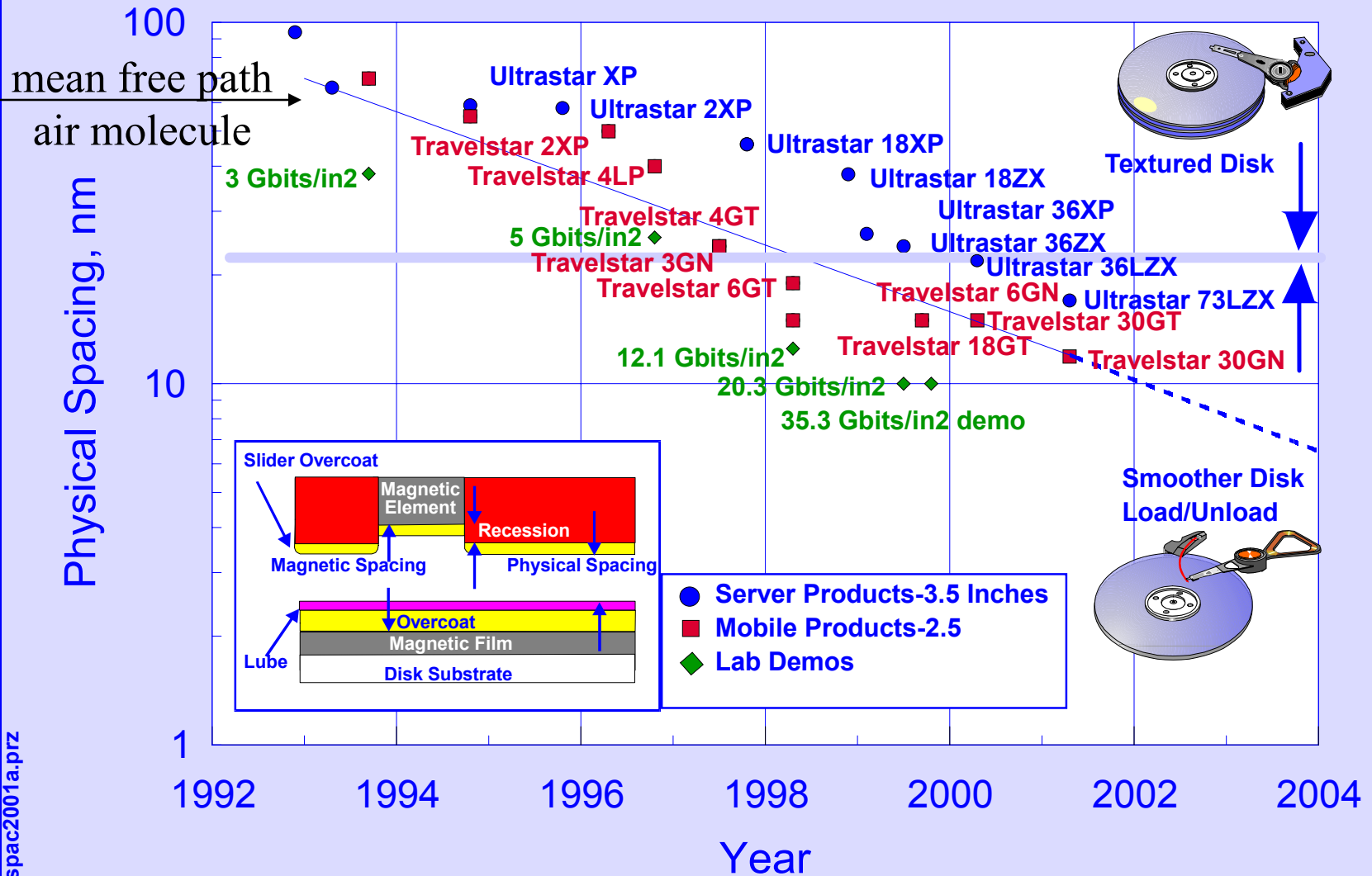
- Shrink everything by factor  $s$  (including currents and microstructure)
- Areal density of data increases  $s^2$

**But:**

- Requires vastly improved processes
- Signal to noise drops (→ improve media, head, electronics)
- volumes scale by  $s^3$  and surface/volume scales as  $1/s$
- current densities increases by  $1/s$  ( $\propto 10^7$  A/cm $^2$ )
- Physics no longer scales



# Physical spacing and disk surface evolution



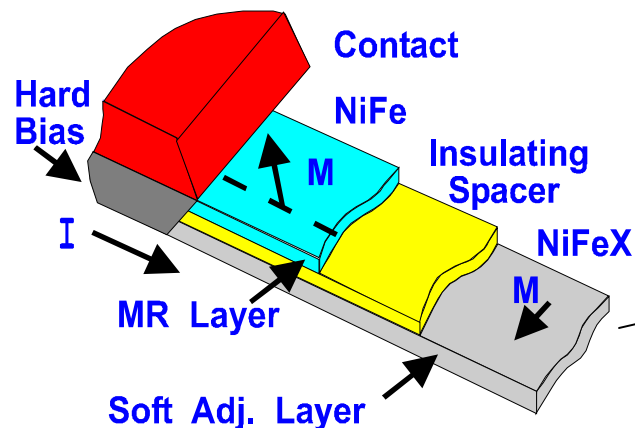
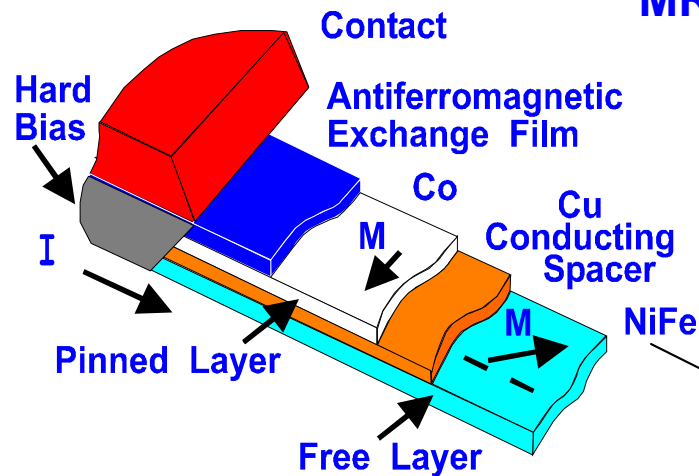
spac2001a.prz



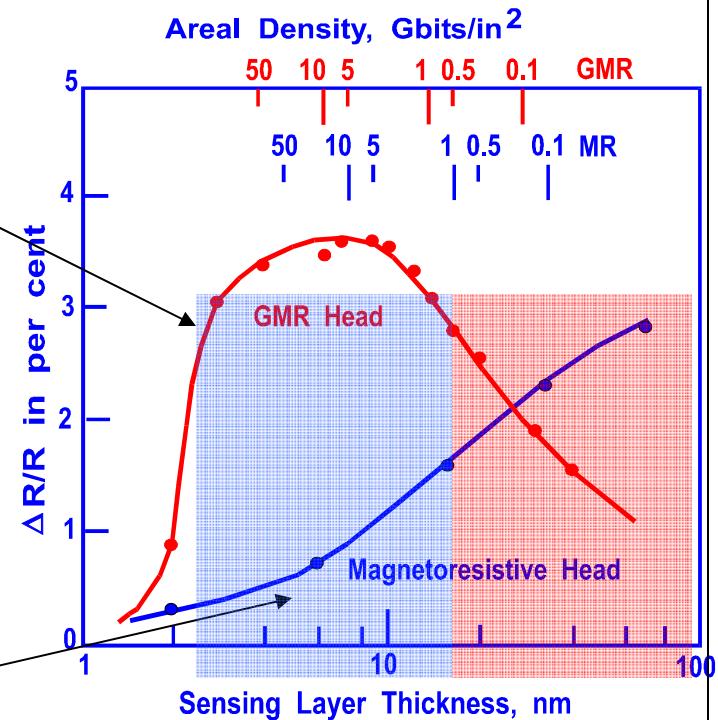


# GMR sensors and scaling

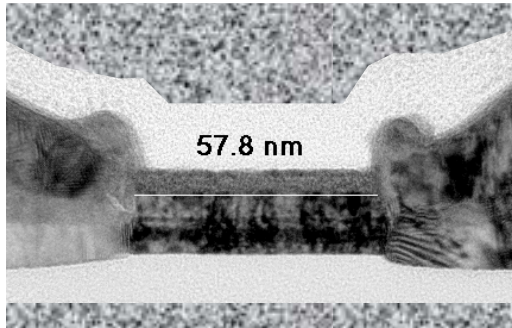
## MR and GMR/Spin Valve Head Characteristics



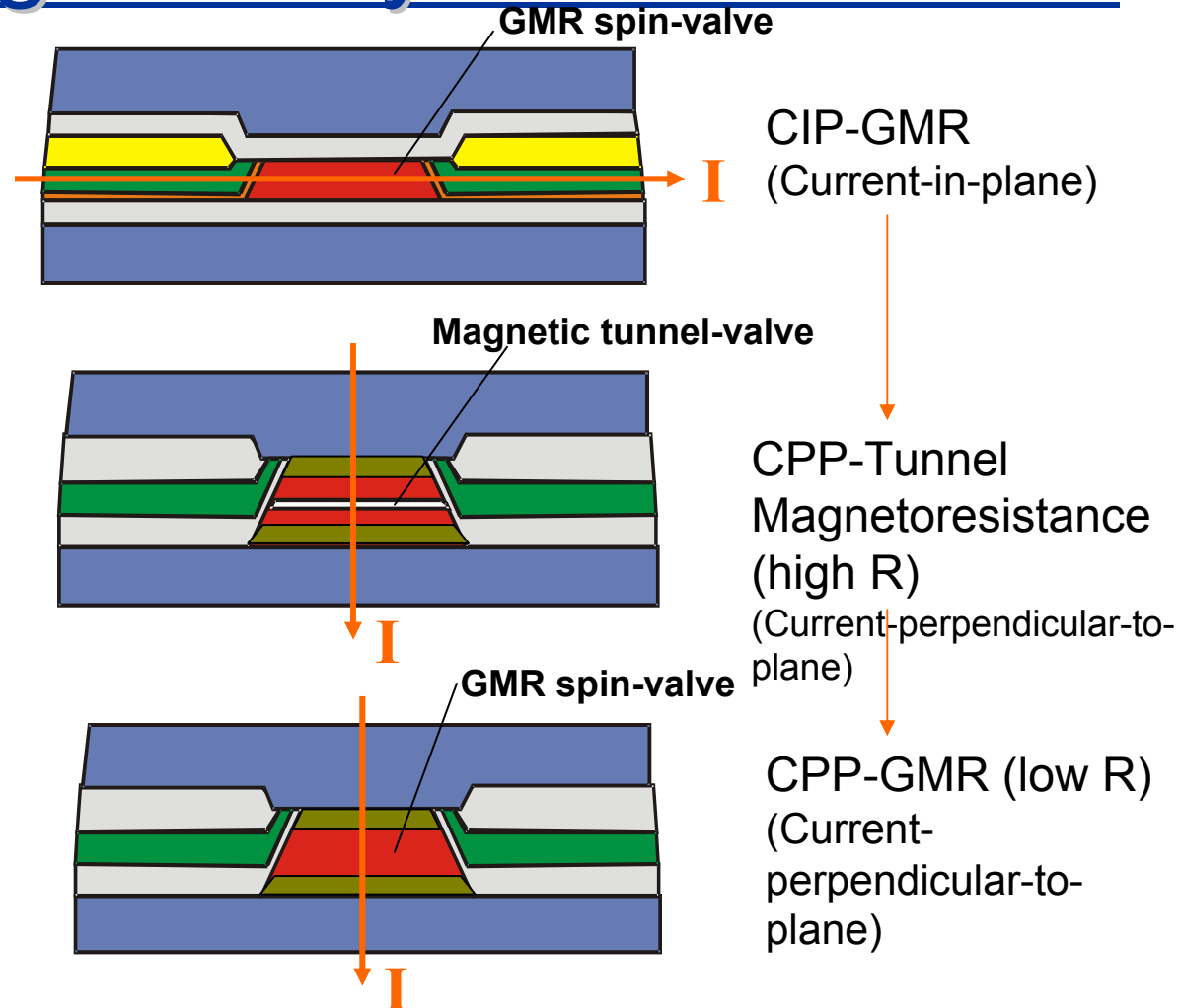
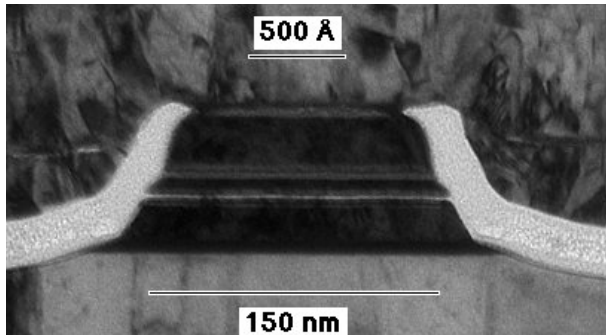
Spin dependent scattering in a single alloy



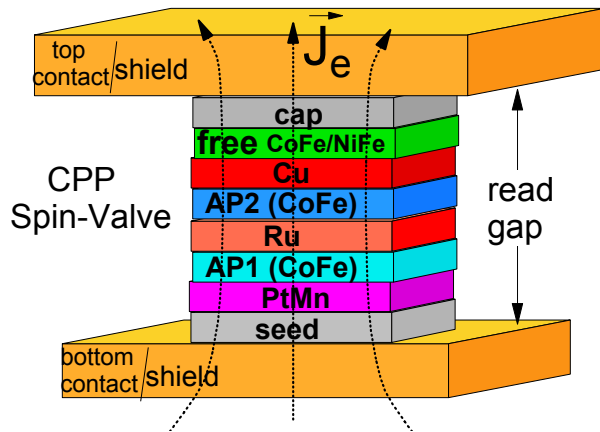
# New sensor geometry



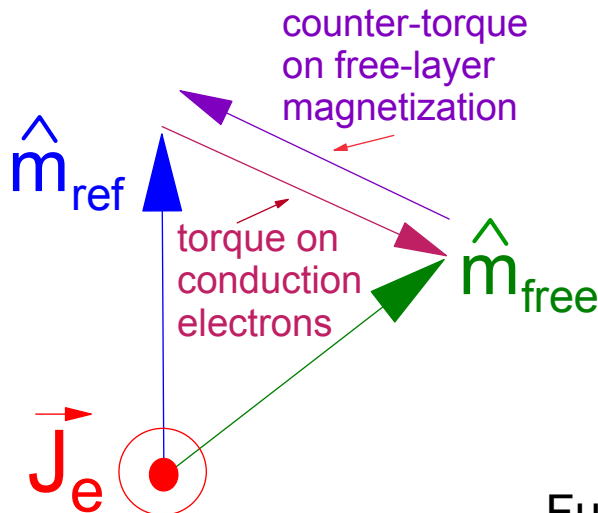
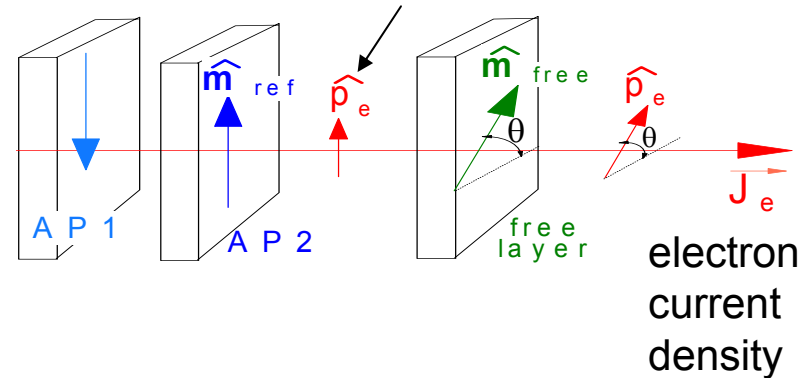
Tunnel-valve head



# Spin torque effects



Polarized conduction electrons



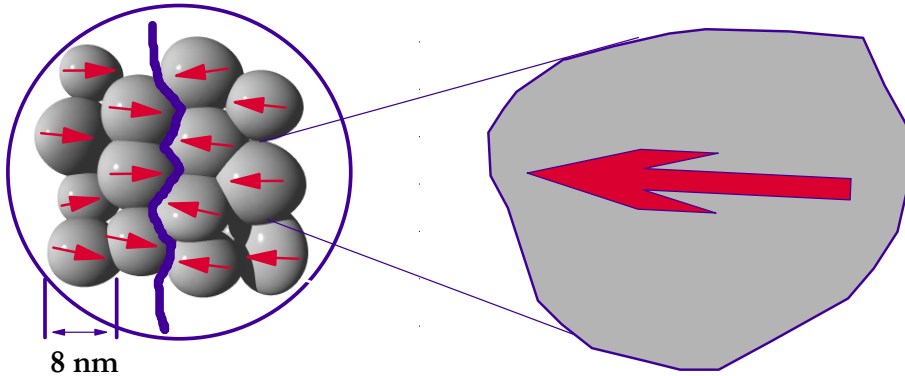
From simple angular momentum conservation (no reflections):

$$\Rightarrow \frac{d\hat{m}_{\text{free}}}{dt} = \frac{\gamma \hbar}{2e M_s t_{\text{free}}} P \vec{J}_e (\hat{m}_{\text{free}} \times \hat{m}_{\text{ref}} \times \hat{m}_{\text{free}})$$

Depends on **polarity** of  $\vec{J}_e$

Full ref: J. Slonczewski, JMMM **159**, L1 (1996)  
Katine et al., PRL (2000)

# Superparamagnetic limit



*Magnetic energy  $E = K_U V$*

Increase  $E_B$  for stability:

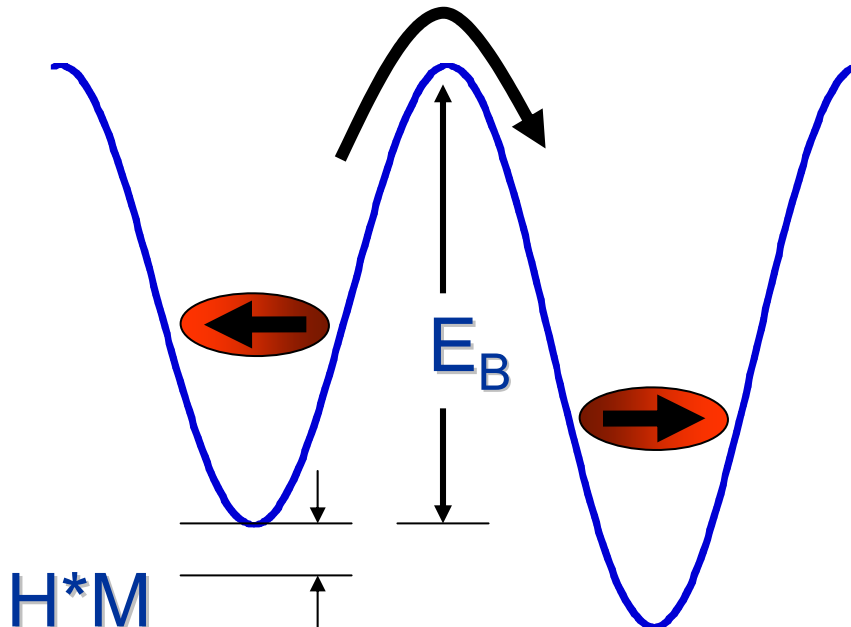
$$E_B \sim K_U V (1 - H/H_0)$$

$$\tau^{-1} \sim \mathbf{f_0} \exp(-E_B/k_B T)$$

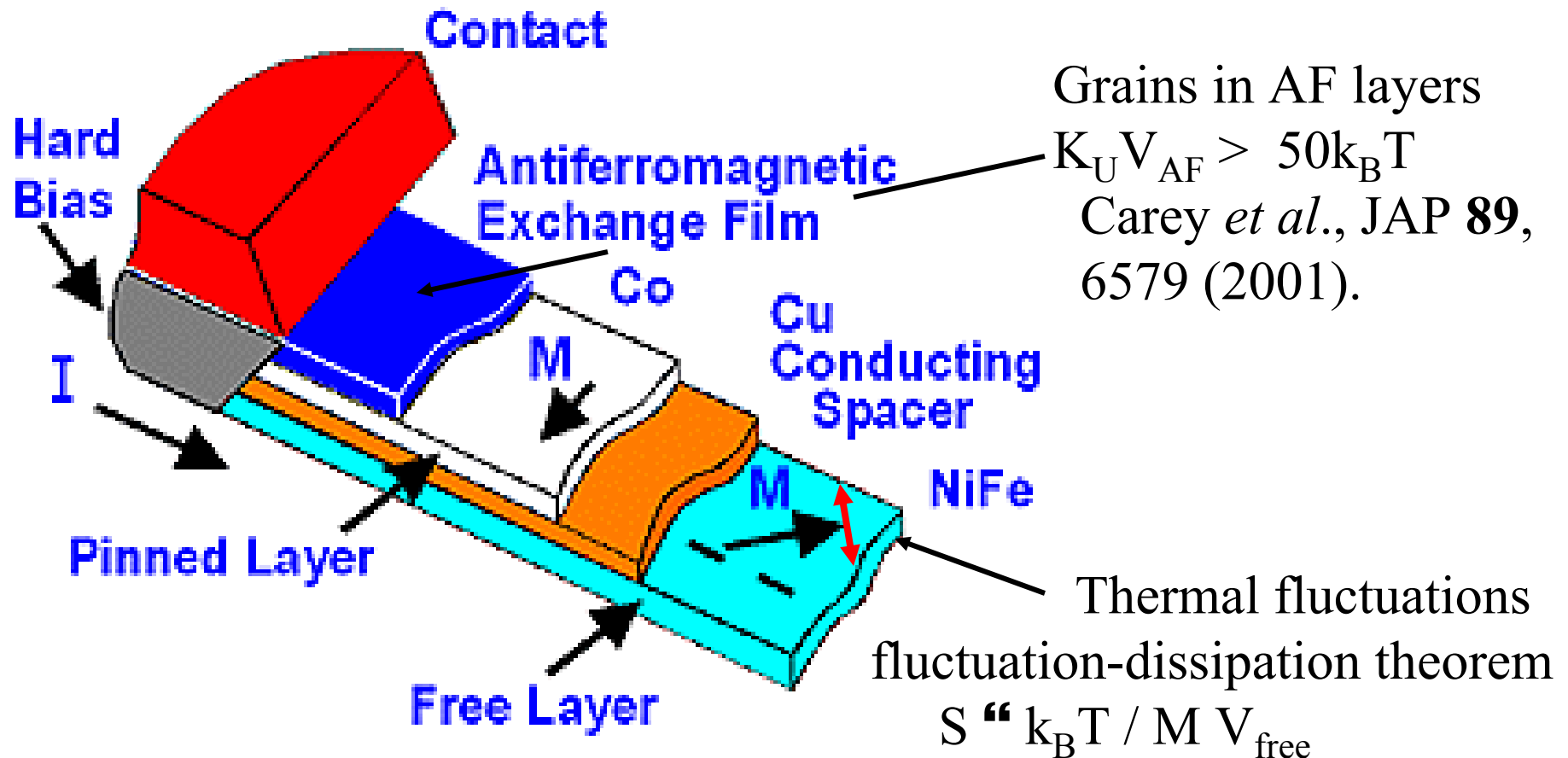
$\uparrow$   
 $10^9/\text{sec}$

But also need:

Coercive field  $H_C \sim K_U/M_S < H_{\text{Write-head}}$

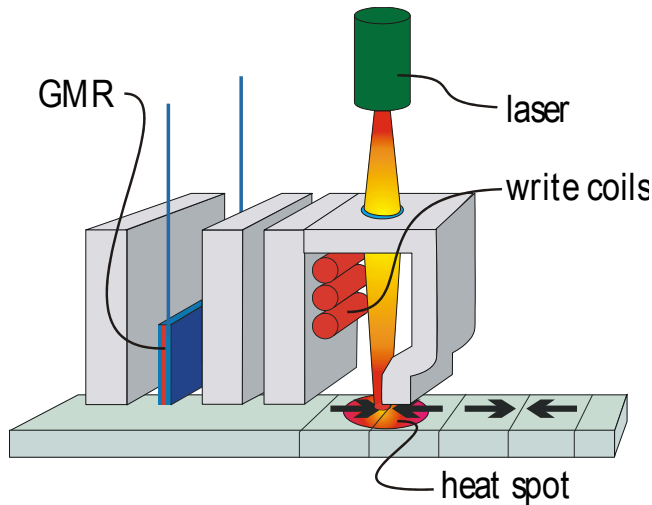
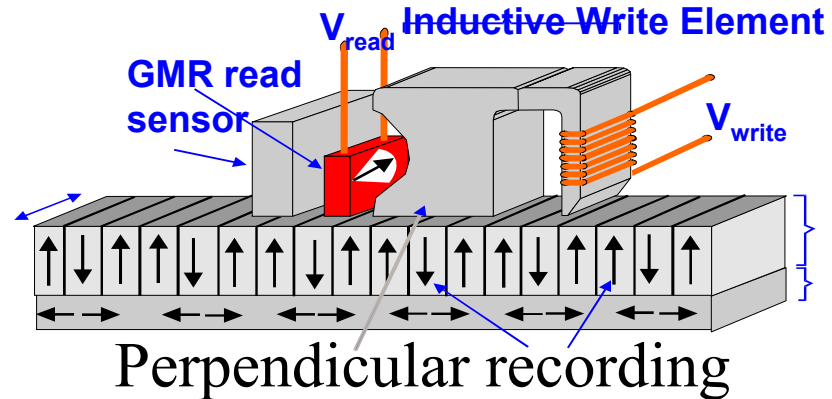
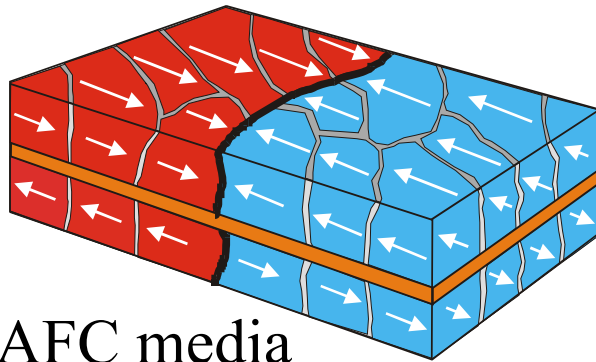


# GMR sensor

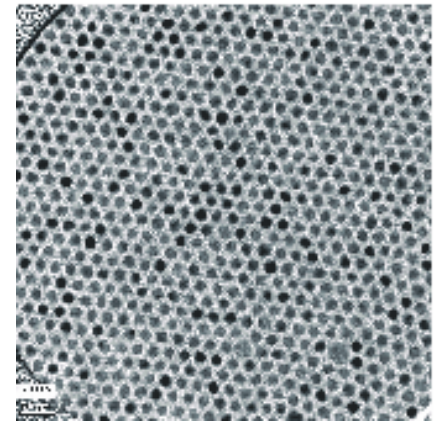
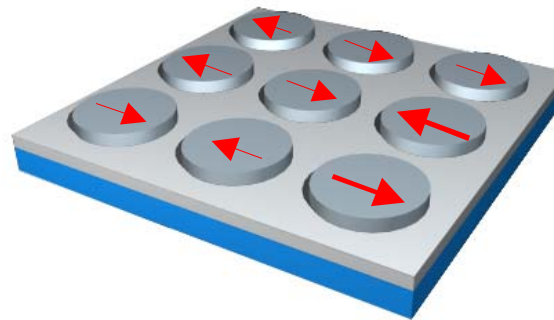


Smith and Arnett, APL **78**, 1448 (2001).

# Advanced media and systems



Thermal assisted recording

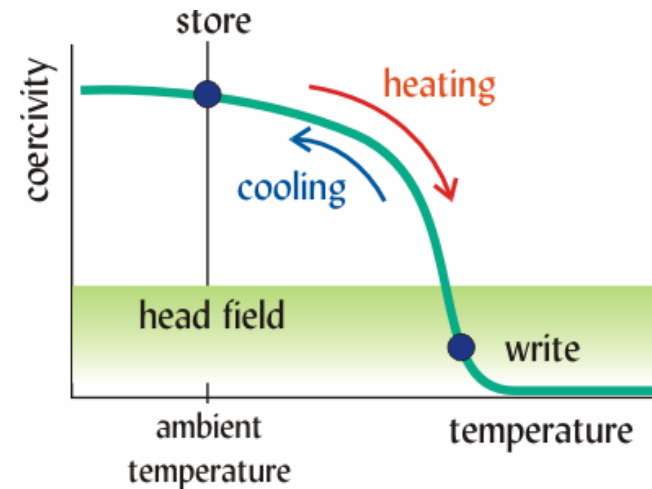
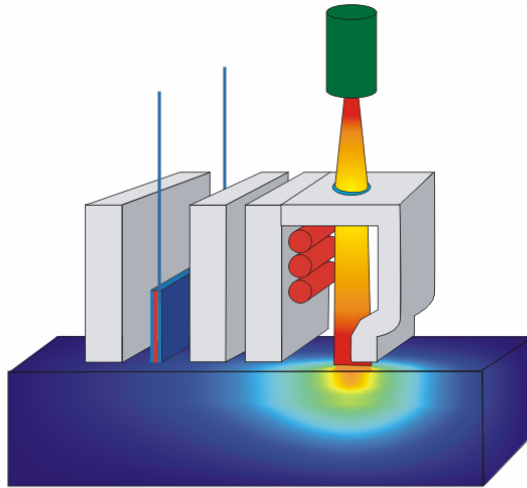


S. Sun, IBM

Moser et al., J. Phys. D: Appl. Phys. **35**, R157 (2002).

Terris and Thomson, J. Phys. D: Appl. Phys. **38**, 199 (2005).

# Thermally Assisted Recording

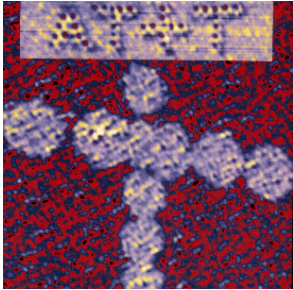


What are the key media and head requirements ?

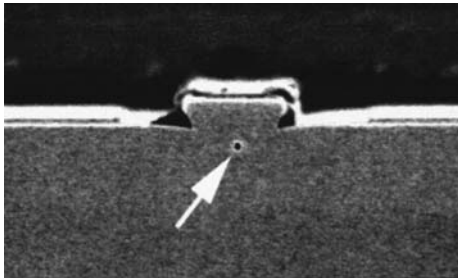
- optical/thermal efficiency
- sub-100 nm heat spot overlapping with magnetic field
- 200 C heating/cooling in 1 ns
- high- $K_U$ , moderate  $T_{\text{write}}$ , small grain size & distribution



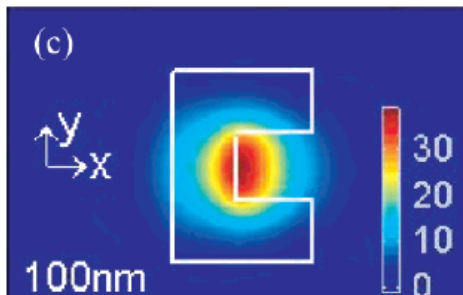
# Thermally Assisted Recording



E. Betzig, et al., *Appl. Phys. Lett.*, **61**, 142 (1992)



Partovi et al., *Appl Phys. Lett.* **75**, 1515 (1999)



X. Shi, L. Hesselink, *JJAP* 41-3B (2002) p1632

Far field, the light intensity normalized to the incident intensity and hole diameter is

$$P_{\text{far}}/\text{Area} \propto (d/\kappa)^4$$

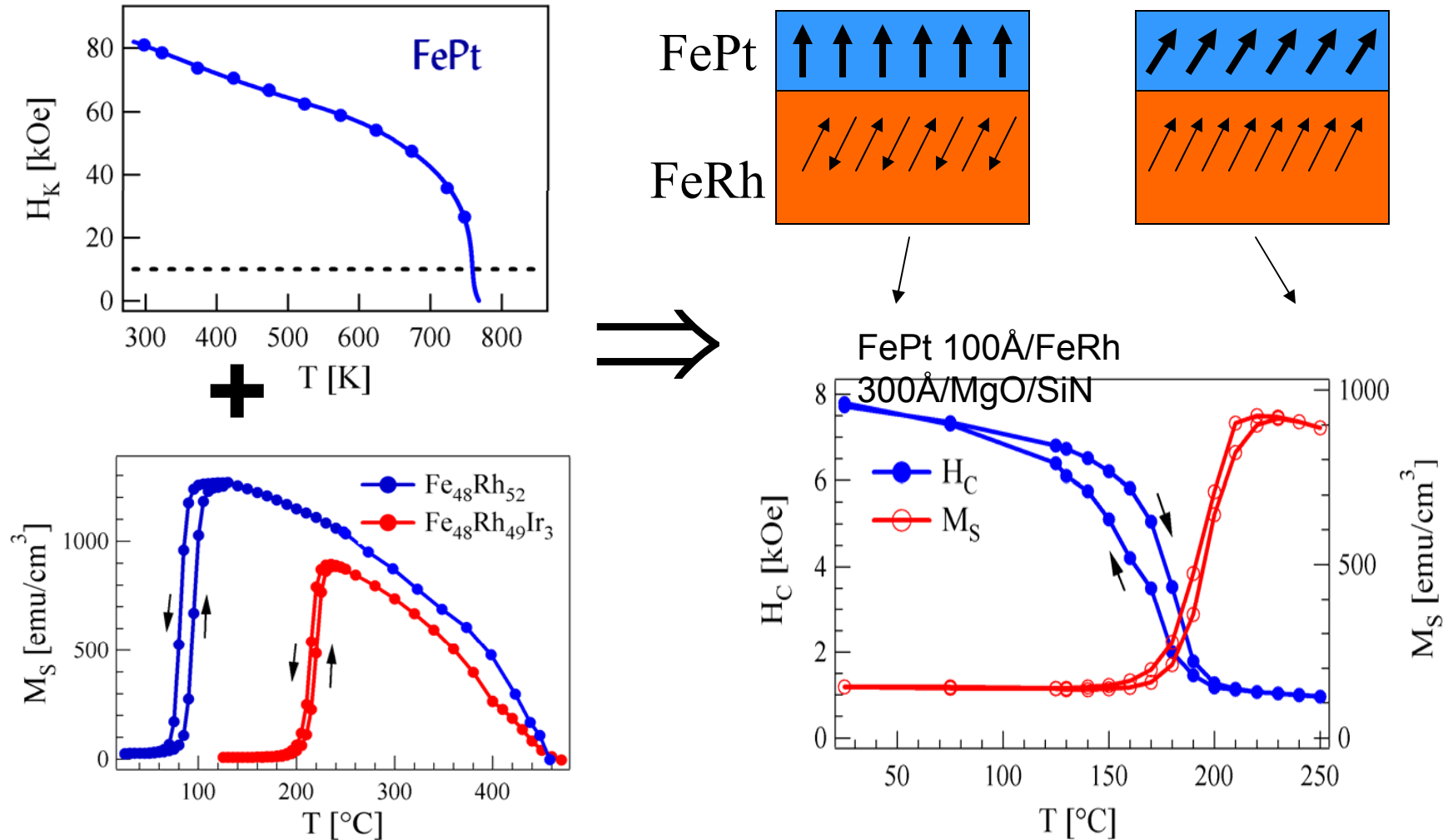
close to the hole, the normalized intensity is

$$P_{\text{close}}/\text{Area} \propto (d/\kappa)^2$$

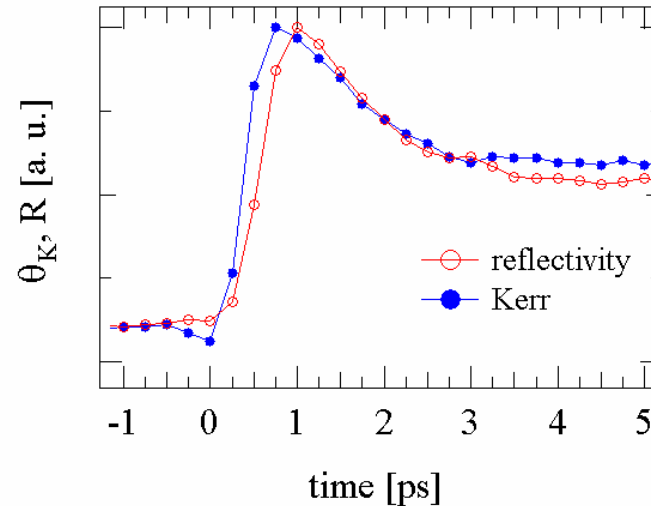
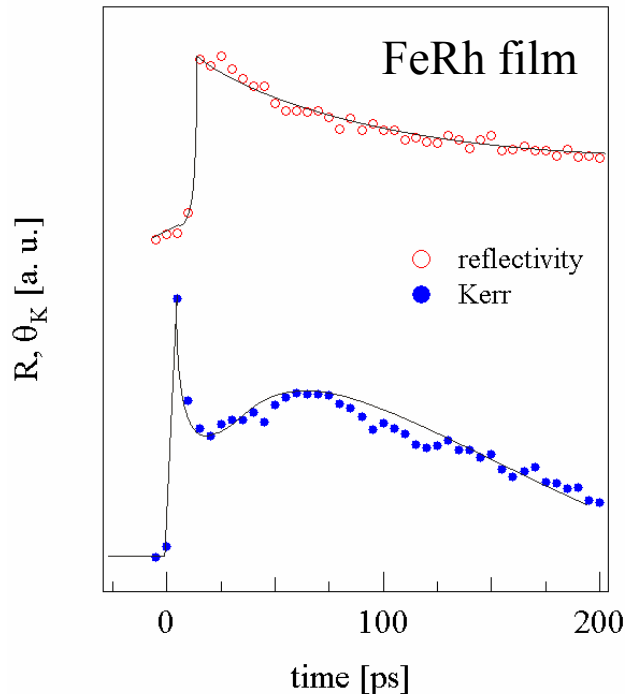
H. A. Bethe, *Phys. Rev.* **66**, 163 (1944)

resonant structures seem to provide required transmission

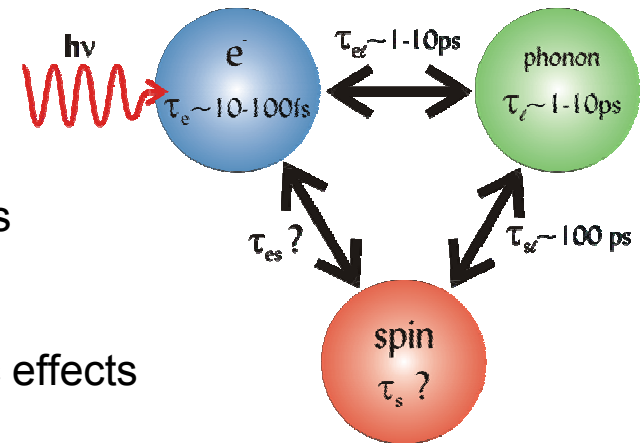
# Two layer recording media



# Two layer recording media



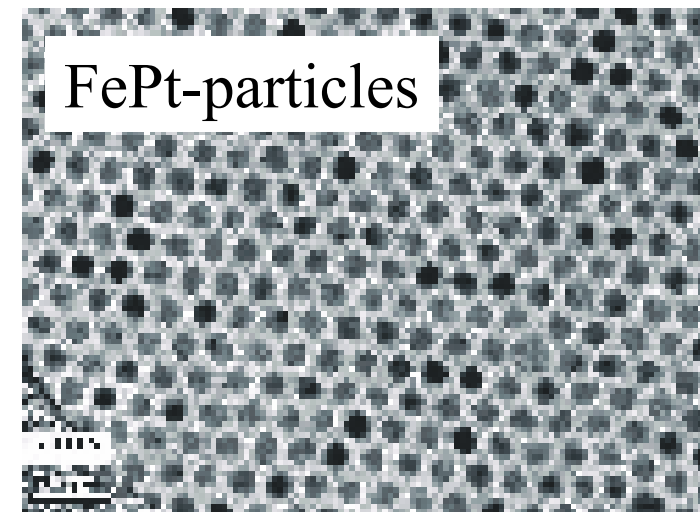
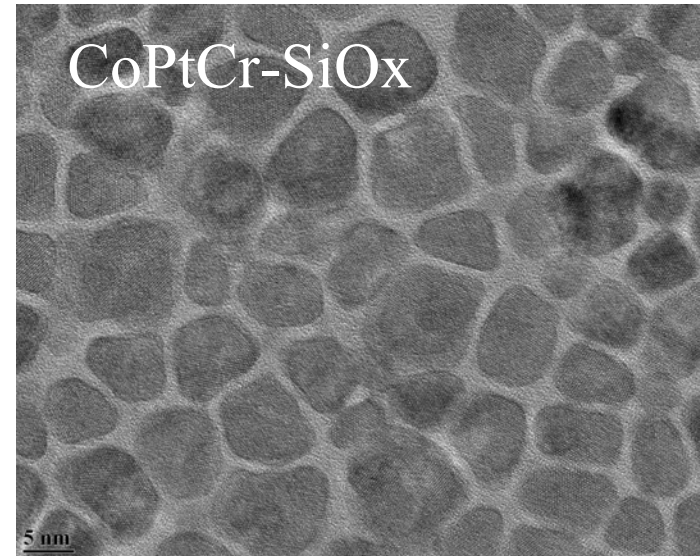
- Kerr response on 10ps time scale qualitatively resembles expected behavior,
- rise time  $\sim 500$  fs: AF-FM transition can be fast
- too fast for lattice – AF-FM transition driven by electronic effects
- interesting physics



# Nano 'issues'

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- control of nano structural order
  - chemical segregation
  - lithography
  - self-assembly
- thermal energy
  - spin wave modes of small structures
  - collective modes
- high current densities
  - dipole fields, spin torques, heating
- sub-ns reversal
- particle-to-particle variations
- particle-to-particle interactions



# Nano solutions

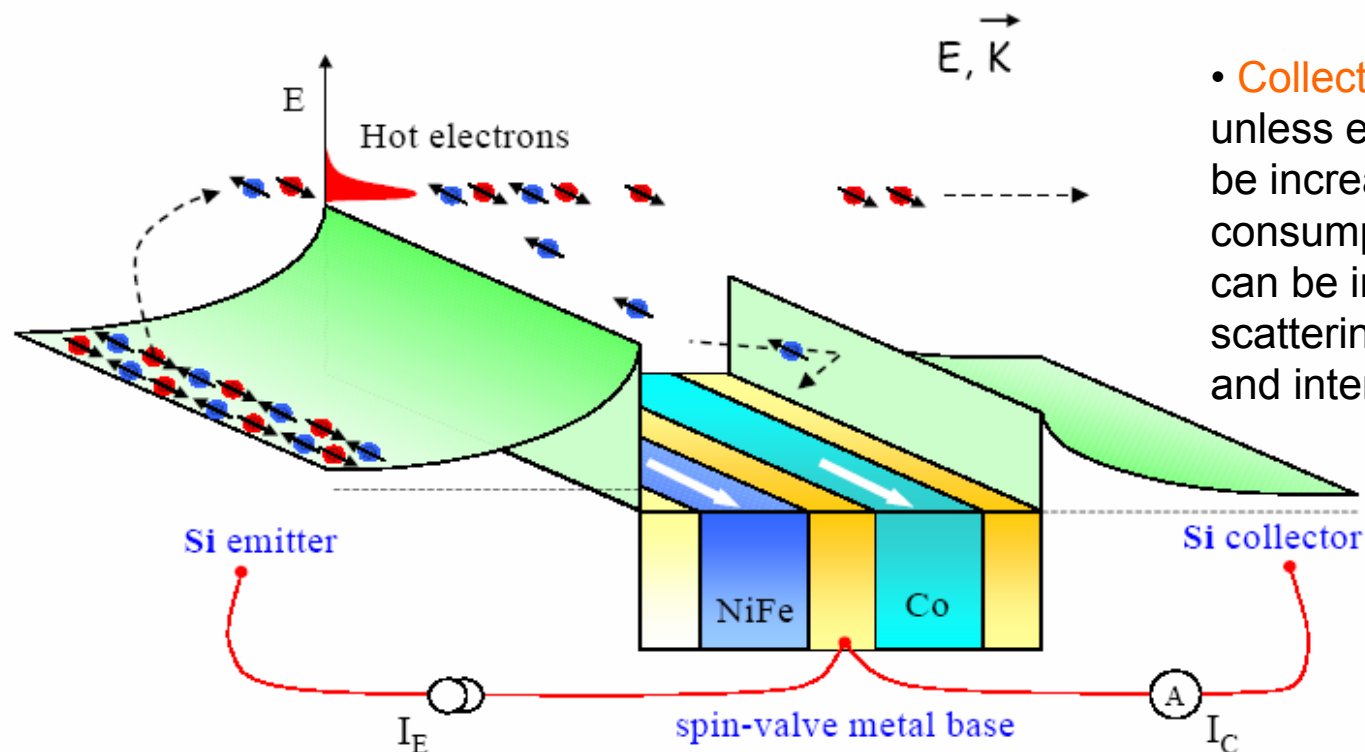
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- New materials and architectures
  - Combine disparate materials at the nm scale
    - e.g. magnet/non-magnetic/magnetic (GMR and RKKY interlayer coupling)
    - FM/AF layers: exchange bias
  - Metal/semiconductor
  - Move to 3D hetero-structures
  - Competing interactions

# Spin-valve Transistor

Monsma et al. (1995); Jansen et al. (2000)

Maximum MC observed  $\sim 560\%$  at 80 K

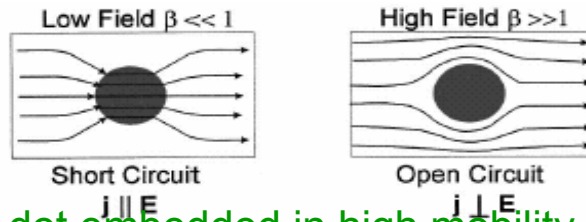


- **Magnetoconductance** ( $>400\%$ ) from spin-dependant hot-electron relaxation in spin-valve base.

- **Collector current small** ( $\mu\text{A}$ ) unless emission current  $I_E$  can be increased (breakdown, power consumption) or transfer ratio can be increased (thinner, less scattering non-magnetic layers and interfaces)

- Hot electron energy is limited by emitter Schottky barrier height.

# Extraordinary Magnetoresistance (EMR)



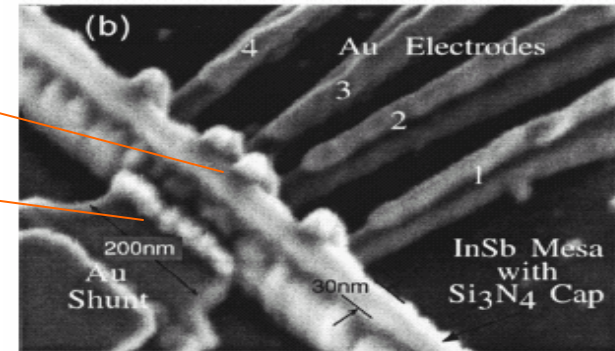
Metal dot embedded in high mobility low carrier density semiconductor (i.e. InSb).

At low field  $E$  is  $\parallel$  to metal/SC boundary and  $j$  follows  $E \rightarrow$  low  $R$ .

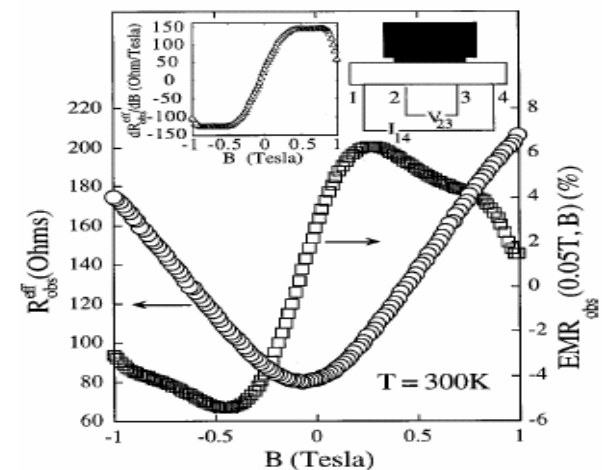
At high fields because of the Lorentz force the angle between  $j$  and  $E$  can approach 90 degrees with little current flowing through metal  $\rightarrow$  high  $R$ .

High-mobility SC

Metal shunt



Solin, APL 80, 4012 (2001)





# Nano solutions

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- Characterization at the relevant time and length scales.
  - Both magnetic and structural sensitivity
  - atomic depth resolution
  - <10 nm lateral resolution
  - <ns temporal resolution
  - buried interfaces
- Neutron and synchrotron facilities are key
  - Resonant x-ray techniques
  - Elemental and magnetic sensitivity via core level resonances, 1-2 nm wavelengths, scattering and imaging down to  $\approx$ 30 ps time resolution.